

Docket No.: 213480US0

## OBLON SPIVAK MCCLELLAND MAIER & NEUSTADT

COMMISSIONER FOR PATENTS ALEXANDRIA, VIRGINIA 22313

ATTORNEYS AT LAW

P.C.

RE: Application Serial No.: 09/942,626

Applicants: Sei TSUNODA, et al.

Filing Date: August 31, 2001

For: LOW DIELECTRIC CONSTANT MATERIAL

HAVING THERMAL RESISTANCE, INSULATION FILM BETWEEN SEMICONDUCTOR LAYERS USING THE SAME, AND SEMICONDUCTOR

**DEVICE** 

Group Art Unit: 1751

Examiner: VIJAYAKUMAR, K.M.

SIR:

Attached hereto for filing are the following papers:

Amendment Under 37 CFR 1.312; Copy of Form PTO-1449 as filed August 26, 2005

Our check in the amount of -0- is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND, MAIER & NEUSTADT, P.C. Norman F. Oblon

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CCFY



08MM&N-rile No. <u>213480US0</u>

Dept.:
By: NFO/HAP/scs

Serial No. <u>09/942,626</u>

In the matter of the Application of: Sei TSUNODA, et al.

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Due Date: <u>N/A</u>

The following has been received in the U.S. Patent Office on the date stamped her-

■ Check for \$180.00

■ Dep. Acct. Order Form

■ Information Disclosure Statement

■ PTO-1449

■ Cited References 3

■ Japanese Office Action with English translation-in-part







OSMM&N File No. <u>213480US0</u>

Dêpt.: C

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- Dep. Acct. Order Form
- PTO Cover Letter
- Amendment Under 37 CFR 1.312
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